Special Issue

Development of Smart Materials for Chemical Sensing

Message from the Guest Editors

This Special Issue focuses on the latest advances in the development of smart materials for application in chemical sensing. A comprehensive assessment and demonstration of material development processes as a key factor in the production of high-quality chemical sensors will be an advantage. Different material processing techniques and state-of-the-art characterization to showcase the art of material fabrication will be considered. Top-down and bottom-up approaches with different phases of resource materials and other green and smart procedures for material growth or deposition will be considered. Detailed discussions of material growth mechanisms remain a critical issue in the understanding and control of material growth processes.

Guest Editors

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Deadline for manuscript submissions

30 September 2025



Processes

an Open Access Journal by MDPI

Impact Factor 2.8 CiteScore 5.5



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Editor-in-Chief

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